Vacuum Ultraviolet Generation via Wave-Mixing

Nonlinear medium

- crystals
- metal vapors
- noble gases

Again Maxwell's framework: coupled wave equations

$$\frac{d}{dz}\mathbf{E}_{q} = i\frac{2\pi(q\omega)^{2}}{ck_{q}}\mathbf{P}_{q}^{NL}$$
$$\mathbf{E}_{q} \quad \text{and} \quad \mathbf{P}_{q}^{NL}$$

Fourier components of fields at frequency $q\omega$ Fields:

 $\mathbf{E}_q = \hat{\mathbf{E}}_q(z,t) \exp[ik_q z]$

THG

Nonlinear polarization has several terms:

$$\mathbf{P}_{3}^{NL} = \frac{N}{4} \left[3\chi_{T}^{(3)}(3\omega) \mathbf{E}_{1} \mathbf{E}_{1} \mathbf{E}_{1} + \chi_{S}^{(3)}(3\omega) \mathbf{E}_{3} |\mathbf{E}_{3}|^{2} + \chi_{S}^{(3)}(\omega, 3\omega) \mathbf{E}_{3} |\mathbf{E}_{1}|^{2} \right]$$



General issues in four wave mixing or third harmonic generation:

Susceptibility of the medium : involves transition dipoles in atoms and resonances

Transparency : problems at short wavelengths

Phase-matching : including the effects of focused laser beams

Practical limitation: optical breakdown

Phase-matching and focusing

Three processes of four-wave mixing:

I	$\omega_1 + \omega_2 + \omega_3 \to \omega_4$
II	$\omega_1 + \omega_2 - \omega_3 \rightarrow \omega_4$

III $\omega_1 - \omega_2 - \omega_3 \rightarrow \omega_4$

Electric fields:

$$\mathbf{E}(\mathbf{r},t) = \operatorname{Re}[\mathbf{E}_{1}(\mathbf{r})\exp(-i\omega_{1}t) + \mathbf{E}_{2}(\mathbf{r})\exp(-i\omega_{2}t) + \mathbf{E}_{3}(\mathbf{r})\exp(-i\omega_{3}t)]$$

Define optical beams as lowest order Gaussians for each frequency ω Gaussian beam TM₀₀ (\rightarrow higher order modes give differing results !)

$$\mathbf{E}_{n}(\mathbf{r}) = \mathbf{E}_{n0}(\mathbf{r}) \frac{\exp(ik_{n}z)}{1+i\xi} \exp\left[\frac{-k_{n}\left(x^{2}+y^{2}\right)}{b\left(1+i\xi\right)}\right]$$

Confocal parameter b

$$b = \frac{2\pi w_0^2}{\lambda} = \frac{2\pi w_0^2 n}{\lambda_0} = \frac{2\lambda_0}{n\theta^2} = kw_0^2$$



 w_0 beam waist radius *n* index of refraction θ far-field diffraction angle

 $\xi = \frac{2(z-f)}{b}$ normalized coordinate along z

Nonlinear Polarization

Newly generated field via processes I, II, III

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},\omega_{2},\omega_{3})E_{1}(\mathbf{r})E_{2}(\mathbf{r})E_{3}(\mathbf{r})$$

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},\omega_{2},-\omega_{3})E_{1}(\mathbf{r})E_{2}(\mathbf{r})E_{3}^{*}(\mathbf{r})$$

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},-\omega_{2},-\omega_{3})E_{1}(\mathbf{r})E_{2}^{*}(\mathbf{r})E_{3}^{*}(\mathbf{r})$$

 χ the polarizability (per atom) and N density of medium Note degeneracy factors (field amplitudes); those may differ for degenerate fields.

Insert fields with their mode structure:

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},\omega_{2},\omega_{3}) E_{10} E_{20} E_{30} \frac{\exp(ik'z)}{(1+i\xi)^{3}} \exp\left[\frac{-k'(x^{2}+y^{2})}{b(1+i\xi^{2})}\right] \qquad k' = k_{1} + k_{2} + k_{3} = k'' \quad \text{Process I}$$

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},\omega_{2},-\omega_{3}) E_{10} E_{20} E_{30} \frac{\exp(ik'z)}{(1+i\xi)^{2}(1-i\xi)} \exp\left[\frac{(-k''+i\xi k')(x^{2}+y^{2})}{b(1+\xi^{2})}\right] \qquad k' = k_{1} + k_{2} - k_{3} \quad \text{Process II}$$

$$P_{4}(\mathbf{r}) = \frac{3}{2} N \chi^{(3)}(-\omega_{4};\omega_{1},-\omega_{2},-\omega_{3}) E_{10} E_{20} E_{30} \frac{\exp(ik'z)}{(1+i\xi)^{2}(1-i\xi)^{2}} \exp\left[\frac{(-k''+i\xi k')(x^{2}+y^{2})}{b(1+\xi^{2})}\right] \qquad k' = k_{1} - k_{2} - k_{3} \quad \text{Process III}$$

Further steps; Maxwell's equations

Derive amplitudes in a Fourier decomposition; amplitude with wave vector ${\bf K}$

$$P_4(\mathbf{K}) = (2\pi)^{-3} \int_{-\infty}^{\infty} dx'' \int_{-\infty}^{\infty} dy'' \int_{-\infty}^{\infty} dz'' P_4(\mathbf{r}'') \exp[-i\mathbf{K} \cdot \mathbf{r}'']$$

Insert in Maxwell's equation:

$$\nabla \times \nabla \times E_{4}(\mathbf{K})(\mathbf{r}) - k_{4}^{2} E_{4}(\mathbf{K})(\mathbf{r}) = 4\pi k_{0}^{2} P_{4}(\mathbf{K}) \exp[i\mathbf{K} \cdot \mathbf{r}]$$
medium vacuum

For: $\Delta k = k_4 - k'$

Solutions, process I (similar equations for II and III)

$$E_{4}(\mathbf{r}) = i \frac{3N}{2k_{4}} \pi k_{0}^{2} b \chi^{(3)}(-\omega_{4};\omega_{1},\omega_{2},\omega_{3}) E_{10} E_{20} E_{30} \frac{\exp(ik'z)}{(1+i\xi)}$$
$$\exp\left[\frac{-k'(x^{2}+y^{2})}{b(1+i\xi)}\right]_{-\zeta}^{\xi} \frac{\exp[-(ib/2)\Delta k(\xi'-\xi)]}{(1+i\xi')^{2}} d\xi'$$

With integration boundaries:

$$\zeta = 2f/b \qquad \xi = \frac{2(z-f)}{b}$$

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Lecture Notes Non Linear Optics; W. Ubachs

Field $E_4(\mathbf{r})$ to be calculated, integration over x and y, and z to z=L.

$$\int_{0}^{\infty} 2\pi R |E_4(R)|^2 dR \qquad R = \sqrt{x^2 + y^2}$$

Result, generally: - Modes cylindrically symmetric around z-axis -Only for Process I the generated beam has lowest order Gaussian

The phase-matching can be quantified:

Phase-matching in $\chi^{(3)}$ Processes

Define the phase-matching integrals:

$$F_{j}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right) = \frac{8}{9} \frac{k_{4}^{2}k'}{\pi^{3}k_{0}^{4}} \frac{1}{b^{3}\chi^{2}|E_{10}E_{20}E_{30}|^{2}} \int_{0}^{\infty} 2\pi R|E_{4}(R)|^{2} dR$$

For all three processes, *j*=I,II,III

Dimensionless parameters, defining geometry and phases.

Then generated Power at P_4 is

$$P_{4} = \eta \frac{k_{0}^{4}k_{1}k_{2}k_{3}}{k_{4}^{2}k'} N^{2}\chi^{2}P_{1}P_{2}P_{3}F_{j}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right)$$

Degeneracy factor

Phase-matching integral for Process I

$$F_{I}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right) = \left|\int_{-\zeta}^{\zeta} \frac{\exp\left[-\left(ib/2\right)\Delta k\xi'\right]}{\left(1+i\xi'\right)^{2}}d\xi'$$

This integral can be evaluated for various conditions, for example in the "tight-focusing limit", b<<L and integrating



Phase-matching integrals F_i for processes and geometries

For "tight-focus" $b/L \ll 1$ "half-way" the cell f/L = 0.5

Process I:

 $F_{I}(b\Delta k, 0, 0.5, 1) = \frac{\pi^{2}(b\Delta k)^{2}e^{(b\Delta k/2)} - \Delta k < 0}{0} - \Delta k \ge 0$

Similarly for Process II and III (if k'=k'' assumed; lowest order mode)

$$F_{II}(b\Delta k, 0, 0.5, 1) = \pi^2 e^{\left(-b|\Delta k|\right)}$$

$$F_{III}(b\Delta k, 0, 0.5, 1) = \frac{0}{\pi^2 (b\Delta k)^2} e^{(b\Delta k/2)} - \Delta k \ge 0$$

General conclusion:

THG (Process I) only possible, in the tight-focusing limit if $\Delta k < 0$

So: only if the medium has NEGATIVE DISPERSION !!

This also holds for sum-frequency mixing

Difference frequency mixing for any k

Numerical approach evaluating F_i ; all near tight focus

Phase-matching integral including

- 1) Dispersion
- 2) Phase evolution through focal region

$$F_{j}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right)$$



 $F_{\rm I}$ versus bAk for b/L < 0.1 and f/L=0.5





Varying the tightness of focus b/L and the mode function k''/k'



Results in the "plane-wave" limit



$$\lim_{b/L \to \infty} F_I\left(b\Delta k, \frac{b}{L}, 0.5, \frac{k''}{k'}\right) = \frac{4L^2}{b^2}\operatorname{sinc}^2\left(\frac{\Delta kL}{2}\right)$$

Note the similarity with analysis of frequency-doubling in crystal; This was done for plane parallel fields!

At b/L ~3 the peak has shifted to the real plane-wave limit already, peaking at $\Delta k=0$.

Note also the decrease in intensity for the plane-wave limit case.

Tight-focusing is more efficient !







Shifting the focus; playing with the phase build-up



For near-tight-focusing of b/L=0.1 Focal positions f/L=0.5 toward f/L=1.5 In latter case focus shifts outside the cell And effectively plane-wave limit is reached.



Near the true plane-wave limit at b/L=10Only small changes to F-integral as long as focus is inside the cell. At f/L=20 the focus is twice the distance of the confocal parameter b/L=10.





Physical interpretation of phase-matching integrals

1) Non-linear polarization peaks at the region of the beam WAIST
→ intensity is highest in focus

2) Phase-matching relates to phase-overlap of all beams involved For a Gaussian beam:

$$\mathbf{E}_{n}(\mathbf{r}) = \mathbf{E}_{n0}(\mathbf{r}) \frac{\exp(ik_{n}z)}{1+i\xi} \exp\left[\frac{-k_{n}\left(x^{2}+y^{2}\right)}{b(1+i\xi)}\right]$$



For tight-focusing:

$$\xi = -2$$
 \longrightarrow $z = f - b$

 $\xi = 2 \qquad \longrightarrow \qquad z = f + b$

Boundaries of focus at windows.

Laser Centre vrije Universiteit amsterdam Lowest order Gaussian beam undergoes phase shift

 $\arctan \xi$

when propagating through the focus (Gouy phase), adding up to π for $(-\infty,\infty)$

Driving polarization undergoes

$3 \arctan \xi$	Process I
$\arctan \xi$	Process II
– arctan ξ	Process III

Optimum conversion if generated field is in phase with driving fields. Generated beam undergoes phase slip: $\arctan \xi$

In-phase for Process II, destructive for I and III

Phase-slips compensated by DISPERSION

-2.2/b	I
$\Delta k_{opt} \cong 0$	II
2.2/b	III

Optimizing density - dispersion and phase-matching

Nonlinear generation:

$$\mathbf{P}_4 \propto \mathbf{P}_1 \mathbf{P}_2 \mathbf{P}_3 N^2 \chi^2 F_j \left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'} \right)$$

 $N^2 F_j$ can be optimized by varying $N, b\Delta k, b/L, f/L$

if Nvaries - macroscopic effect on medium - index of refraction changes - Δk varies

Phase-mismatch is a dispersion effect and

 $\Delta k = \alpha N$

One can define a dimensionless quantity:

$$G_{j}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right) = \left(b\Delta k\right)^{2} F_{j}\left(b\Delta k, \frac{b}{L}, \frac{f}{L}, \frac{k''}{k'}\right)$$



 G_{I} vs. b Δ k for tight-focusing; always OK as long as focus inside the cell.



THG production and dispersion in the noble gases

Third harmonic produced:

$$P_{THG} = \frac{\eta}{(3\lambda)^4} N^2 \Big[\chi^{(3)}(\lambda) \Big]^2 P_1^3 F_j \Big(b\Delta k, \frac{b}{L}, 0.5, 1 \Big)$$

In tight-focusing limit (b<<L):

$$F_{I}(b\Delta k, 0, 0.5, 1) = \frac{\pi^{2}(b\Delta k)^{2}e^{(b\Delta k/2)}}{0} \qquad \Delta k < 0$$

In plane-wave limit (b>>L):

$$F_I(b\Delta k, \infty, 0.5, 1) = \frac{4L^2}{b^2} \operatorname{sinc}^2\left(\frac{\Delta kL}{2}\right)$$

We have seen : tight focus is more efficient, but then negative dispersion required In region of bound states; index of refraction (with f_i the oscillator strength of transitions)

$$(n-1)_{lines} = \frac{Nr_e}{2\pi} \sum_i \frac{f_i}{\lambda_i^{-2} - \lambda}$$

In the continuum (σ ionization cross section)

$$(n-1)_{continuum} = \frac{N}{2\pi} \int \frac{\sigma}{\overline{v_i}^2 - \overline{v}^2} d\overline{v_i}$$

Cross sections and oscillator strength relate to atomic structure, with C the phase mismatch per atom;

$$\Delta k = CN = \frac{2\pi (n_1 - n_3)}{\lambda}$$

Calculation of regions of positive and negative dispersion

Negative and positive dispersion in the Kr and Xe

Shaded areas - "anomalous dispersion in the medium"



Regions of efficient THG



THG in Xe; experiment



Conclusion: 1) theory of phase-matching works 2) THG effective at blue side of ns and nd resonances



Experimental density effect on phase matching in Xe



Tight focusing at λ = 118 nm in Xe (negative dispersion); b/L = 0.025 f/L =0.5 - centre of cell

Effect of G-integral and interplay between N and Δk .

Defeating the negative dispersion problem

All calculations performed for integral from -L to +L. Cut-off the medium at f; stop the destructive interference. Can be done in "forbidden region". Efficiency remains low; but not zero.





Resonance enhanced VUV production

Non-linear susceptibility:

$$\chi^{(3)} \propto \sum_{gijk} \sum_{terms} \frac{\langle g | \mathbf{r} | i \rangle \langle i | \mathbf{r} | j \rangle \langle j | \mathbf{r} | k \rangle \langle k | \mathbf{r} | g \rangle}{(\omega_{gi} \pm \omega) (\omega_{gj} \pm 2\omega) (\omega_{gk} \pm 3\omega)}$$

Resonances possible at the

- One photon
- Two-photon
- Three photon levels

Advantage at two-photon-level

$$\chi^{(3)} \propto \sum_{ik} \sum_{terms} \frac{\langle g | \mathbf{r} | i \rangle \langle i | \mathbf{r} | J' \rangle \langle J' | \mathbf{r} | k \rangle \langle k | \mathbf{r} | g \rangle}{(\omega_{gi} \pm \omega) (\omega_{gj} - 2\omega - i\Gamma) (\omega_{gk} \pm 3\omega)}$$



Process I





Lecture Notes Non Linear Optics; W. Ubachs

Again level structure of the noble gases is favorable:

Two-photon resonance	excitation energy (cm ⁻¹)	resonance wavelength (nm)	relative efficiency ^a		
5p - 6p' [3/2] ₂	89162.9	224.3	40		
[1/2]	89860.5	222.6	187		
7p [5/2] ₂	88352.2	226.4	4		
Xe [3/2] ₂	88687.0	225.5	9		
[1/2] ₀	88842.8	225.1	26		
8p [5/2] ₂	92221.9	216.9	9		
[3/2] ₂	92371.4	216.5	5		
[1/2] ₀	92555.7	216.1	119		
4p - 5p [5/2] ₂	92308.2	216.7	167		
Kr [3/2] ₂	93124.1	214.8	56		
[1/2] ₀	94093.7	212.6	1000		
^a Fundamental power is 20 kW.					

λ = 212.5 nm resonance in Kr "strongest two-photon resonance in nature"

Non-colinear Phase-matching for sum-frequency generation





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Tensor nature of susceptibility

$$\mathbf{P}_{\sigma}(\omega_{r};\omega_{i},\omega_{j},\omega_{k}) \propto \chi^{(3)}_{\sigma\alpha\beta\gamma} \mathbf{E}^{i}_{\alpha} \mathbf{E}^{j}_{\beta} \mathbf{E}^{k}_{\gamma}$$

Dependent on matrix dipole moments

 $\chi^{(3)} \propto \sum_{gijk} \sum_{terms} \frac{\langle g | \mathbf{r} | i \rangle \langle i | \mathbf{r} | j \rangle \langle j | \mathbf{r} | k \rangle \langle k | \mathbf{r} | g \rangle}{(\omega_{gi} - \omega)(\omega_{gj} - 2\omega)(\omega_{gk} - 3\omega)}$

Note: a COHERENT sum should be taken (as in multi-photon transitions) Parametric and non-parametric processes; relate to energy exchange

Use atomic physics framework: evaluate Transition dipole moments with Wigner-Eckhart theorem:

$$\left\langle g | \mathbf{r} | i \right\rangle = \left\langle J_g M_g | \mathbf{r}_q^{(1)} | J_i M_i \right\rangle = (-)^{J_i - M_i} \begin{pmatrix} J_i & 1 & J_g \\ -M_i & q & M_g \end{pmatrix} \left\langle J_g \| \mathbf{r}^{(1)} \| J_i \right\rangle$$

$$\chi^{(3)} \propto \begin{pmatrix} J_{i} & 1 & J_{g} \\ -M_{i} & q_{1} & M_{g} \end{pmatrix} \begin{pmatrix} J_{j} & 1 & J_{i} \\ -M_{j} & q_{2} & M_{i} \end{pmatrix} \begin{pmatrix} J_{k} & 1 & J_{j} \\ -M_{k} & q_{3} & M_{j} \end{pmatrix} \begin{pmatrix} J_{g} & 1 & J_{k} \\ -M_{g} & q_{4} & M_{k} \end{pmatrix}$$

The coherent sum requires $\Delta M=0$ over four-photon cycle; q=0, q=-1, q=1 projections of dipole moment on angular basis (polarizations) Evaluate the four-product of Wigner-3j symbols

Results: 1) all polarizations linear is possible $q_1 = q_2 = q_3 = q_4 = 0$

2) THG with circular light is NOT possible: $q_1 = q_2 = q_3 = 1$



Polarization in sum-frequency mixing; quantum levels



ω _R	ω _{tun}	ωχυν	J ₂ =0	J ₂ =2
		>	0.333	0.298
	Ť	≜	0.333	-0.149
			0.236	0.211
>		≜	-0.236i	0.105i
C	\mathbf{r}		0	-0.447
		(0	0.316

Well defined quantum level; Real intermediate level J₂ = 0 or 2 Pulsed jets and differential pumping - the road to the windowless regime



A.H. Kung, Opt. Lett. 8, 24 (1983).



Some considerations

- 1) Bandwidth effects
- 2) Lasers and synchrotrons
- 3) The perturbative regime and the non-perturbative -> recollision model
- 4) Spectroscopy in VUV and XUV feasible



XUV-laser setup with PDA; bandwidth ~250 MHz



 $\lambda=90\text{ - 110 nm}$







Measurement of $1^{1}S - 2^{1}P$ resonance line of Helium



* P88(15-1) o component in I₂ at 513049427.1(1.7) MHz

5 130 495 083 (45) MHz

Results on Lamb shift in He ground state

41224 (45) MHz experiment (1997)
41233 (35-100) MHz; Drake (1993)
41223 (42) MHz theory; Korobow/Yelkovsky (2001)

2-electron QED effects in He $(1s^2 {}^1S_0)$

vacuum polarisation

